2024 Fall Admission

International Ph.D. Program in Plasma and Thin Film Technology Ming Chi University of Technology, New Taipei, Taiwan

We are looking for International Ph.D. Students to join the Ph.D. Program in Plasma and Thin Film Technology at Ming Chi University of Technology, Taiwan.

- > Research Area:
- 1. Plasma science & technology
- 2. Thin film technology
- 3. Solar photovoltaic thin film
- 4. Semiconductor process technology
- 5. Nano Biomedicine
- > Stipend option:
- 1. 15,000 NTD/month + Lab Salary
- 2. MOE, Taiwan Scholarship (20,000 NTD/month)
- Accommodation: Free (School dormitory)
- **✓** Eligibility:
- ➤ Master or equivalent degree in a relevant branch of Engineering/Applied Science/Technology
- Good English Skills

Application: Visit https://cia.mcut.edu.tw/?Lang=en and upload your application files

Contact information: Prof. Jyh-Wei Lee (jefflee@mail.mcut.edu.tw)







Ph.D. Program

Deadline: April 01, 2024 (2024 Fall Semester)